

AMENDMENTS TO THE SPECIFICATION

Please amend the specification as follows:

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Paragraph beginning at page 26, line 6:

The electrodes used in the electrolytic molecular assembly growing method were formed on a glass plate. A glass plate of a size of 25 × 10 mm was prepared, and platinum was vapor-deposited on the glass substrate. A mask having a rough shape of the electrodes was printed on an OHP overhead projector sheet. A photoresist agent was spin-coated on the platinum-deposited glass substrate. Spin coating was performed for 60 seconds at a rotation speed of the spin coater of 3,000 rpm. The photoresist agent was dried at 110°C for 1 minute to form a coating film. The glass substrate coated with the photoresist agent was exposed using a mask aligner with a mercury-lamp light source through the mask. Developing was performed using a Microposit Developer MF319 (manufactured by Shipley Far East, Ltd.) for 60 seconds. At that time, the portion not exposed was completely dissolved. The glass substrate was then cleaned with pure water. Thus, the rough shapes of the electrodes were formed.